

Reducing (?) Field Emission from Large Area, High Voltage Electrodes

David Stone Carnegie Mellon University Advisors: Karl Smolenski and Bruce Dunham Cornell University Laboratory for Elementary-Particle Physics



Background

- Electron gun:
 - Photocathode, pulsed laser, stalk, ceramic
 - All under vacuum
- Cathode Voltage
 - Ideally at -750 kV w.r.t. anode (at ground)
 - Cathode must use conditioning, HPR, electrochemical polishing, etc. to decrease imperfections (which become important at high voltage)





Problems

• Ultra-High Vacuum (UHV)

- Maintained to prevent voltage
 breakdown- desorbed or leftover gas
 can initiate breakdown
- In gun, p $\approx 10^{-11}$ torr to prevent decay of QE in photocathode



• High Voltage (HV)

- Breakdown occurs in most gaps w/ excess field strength > 20 MV/m
- Initiated by microprotrusions and other e⁻ emission sites, strong fields at triple junctions, desorbed gas, small gap separations, etc.
- Once initiated, if electron current impacts ceramic, secondary emission and electron avalanches can occur, irreversibly destroying ceramic



The Project- So far

• Ceramic Design

- Stacked/graded insulator design (J.G. Leopold, et al.)

- Varied ceramic angle (45°) & thickness, conductor length & protrusion, etc.
- Not much difference in any design in reducing field strengths in ceramic
- But *geometries* are very important for reduction of secondary electron emission (need an E_⊥ to ceramic surface)
- Modeling with Opera-2d electrostatics module
 - Electron path tracking, equipotential visualization, fields along lines (graphical comparisons)
- Electrode Design
 - Electrochemical polishing of niobium discussion





The Project- So Far

45 Degree Stacked Ceramic: Potential and Electron Tracks





The Project- So Far

45 Degree Stacked Ceramic with Conductor Protrusion: Potential and Electron Tracks





The Project- So Far

45 Degree Stacked Ceramic: Potential







60 Degree Stacked Ceramic: Potential





Vector Fields

Vector Fields



Cornell University Laboratory for Elementary-Particle Physics

The Project- So Far

• Change in Project Direction

- Instead of field emission *reduction*, we focus more on:
 - Field shaping
 - Electron trajectory shaping
- Attaining mastery over these will significantly decrease breakdown during operation







• Ceramic Design

- Further development and testing of stacked design
- Writing Opera-2d scripts to do complex models
- Try out new materials, coating?

• Modified ERL Gun Design

- Try new geometries such as inverted design (Breidenbach, et al.)?
- Implement new ceramic design
- Electrode Testing/Development
 - Conditioning, electrochemical polishing
 - Reducing electrode surface area to reduce possible e⁻ emission sites



- M. Breidenbach, M. Foss, J. Hodgson, A. Kulikov, A. Odian, G. Putallaz, H. Rogers, R. Schindler, K. Skarpaas, M. Zolotorev (SLAC). "An Inverted geometry, high voltage polarized electron gun with UHV load lock." SLAC-PUB-6501, May 1994. 27pp.
- Latham, Rod. High Voltage Vacuum Insulation. Padstow, Cornwall: Academic P, 1995.
- Leopold, John G., Chaim Leibovitz, Itamar Navon, and Meir Markovits. "Different Approach to Pulsed High-Voltage Vacuum-Insulation Design." Phys. Rev. ST Accel. Beams 10. June 2007. 14pp.
- Miller, H.C. "Surface flashover of insulators." Electrical Insulation, IEEE Transactions on. Volume 24, Issue 5, Oct 1989 Page(s):765 786.
- Pierce, J.R. "Rectilinear Electron Flow in Beams." J. Appl. Phys. 11, 548 (1940); DOI:10.1063/1.1712815
- Sinclair, C K. "A 500 KV Photoemission Electron Gun for the CEBAF FEL." Nuclear Instruments and Methods in Physics Research Section A 318 (1992): 410-414.
- Sinclair, C.K., "Very high voltage photoemission electron guns," Particle Accelerator Conference, 2003. PAC 2003. Proceedings of the , vol.1, no., pp. 76-80 Vol.1, 12-16 May 2003.